



INTERNATIONAL  
GEMOLOGICAL  
INSTITUTE

ELECTRONIC COPY

LABORATORY GROWN DIAMOND REPORT

April 4, 2026

IGI Report Number

DESCRIPTION

SHAPE AND CUTTING STYLE

MEASUREMENTS

GRADING RESULTS

CARAT WEIGHT

COLOR GRADE

CLARITY GRADE

CUT GRADE

ADDITIONAL GRADING INFORMATION

POLISH

SYMMETRY

FLUORESCENCE

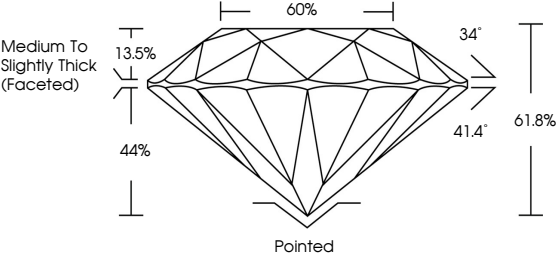
INSCRIPTION(S)

COMMENTS: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa

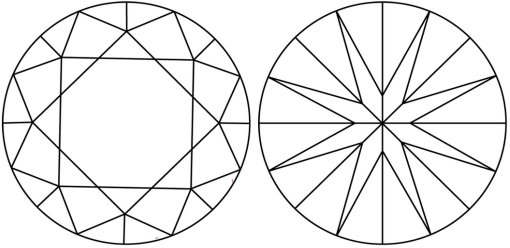
LG788611546

Report verification at igi.org

PROPORTIONS



CLARITY CHARACTERISTICS



KEY TO SYMBOLS

Red symbols indicate internal characteristics.  
Green symbols indicate external characteristics.

COLOR

CLARITY

FL

IF

VVS<sup>1-2</sup>

VS<sup>1-2</sup>

SI<sup>1-2</sup>

I<sup>1-3</sup>

Flawless

Internally Flawless

Very Very Slightly Included

Very Slightly Included

Slightly Included

Included



© IGI 2020, International Gemological Institute

FD - 10 20

LABORATORY GROWN DIAMOND REPORT

April 4, 2026

IGI Report Number

DESCRIPTION

SHAPE AND CUTTING STYLE

MEASUREMENTS

GRADING RESULTS

CARAT WEIGHT

COLOR GRADE

CLARITY GRADE

CUT GRADE

ADDITIONAL GRADING INFORMATION

POLISH

SYMMETRY

FLUORESCENCE

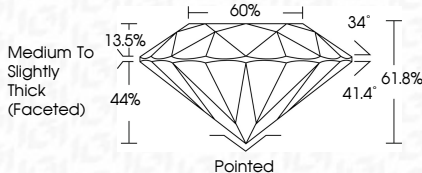
INSCRIPTION(S)

COMMENTS: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa

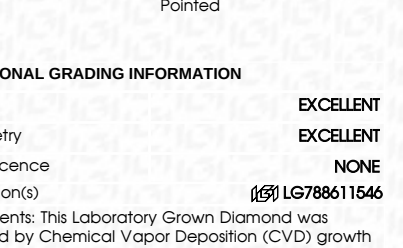
LG788611546

Report verification at igi.org

PROPORTIONS



CLARITY CHARACTERISTICS



KEY TO SYMBOLS

Red symbols indicate internal characteristics.  
Green symbols indicate external characteristics.

COLOR

CLARITY

FL

IF

VVS<sup>1-2</sup>

VS<sup>1-2</sup>

SI<sup>1-2</sup>

I<sup>1-3</sup>

Flawless

Internally Flawless

Very Very Slightly Included

Very Slightly Included

Slightly Included

Included



© IGI 2020, International Gemological Institute

FD - 10 20



THIS DOCUMENT WAS PRODUCED WITH THE FOLLOWING SECURITY MEASURES: SPECIAL DOCUMENT PAPER, INK SCREENS, WATERMARK BACKGROUND DESIGNS, HOLOGRAM AND OTHER SECURITY FEATURES NOT LISTED AND DO EXCEED DOCUMENT SECURITY INDUSTRY GUIDELINES.